

**IN THE CLAIMS:**

Please amend the claims to read as follows:

1. (Currently Amended): A liquid crystal display device, comprising:  
a plurality of gate lines and data lines crossing each other to define a plurality of pixel regions;  
a plurality of thin film transistors, each disposed in one of the pixel regions, the thin film transistor including:  
  - a gate electrode on a first substrate,
  - a gate insulating layer over the first substrate,
  - a semiconductor layer on the gate insulating layer,
  - source/drain electrodes on the semiconductor layer, and
  - a passivation layer over the first substrate including the source/drain electrodes; and  
a plurality of pixel electrodes, each disposed in one of the pixel regions[[],] ~~wherein the thin film transistors include ; and~~  
  
at least one Ti layer on at least one layer of the gate electrode, the semiconductor layer, and the source/drain electrodes of the thin film transistor.

2. (Cancelled).
3. (Original): The device according to claim 2, further comprising a TiO<sub>2</sub> layer formed on at least the passivation layer.
4. (Original): The device according to claim 3, wherein a surface of the TiO<sub>2</sub> layer has hydrophilic properties.
5. (Cancelled).
6. (Currently Amended): The device according to claim ~~[[5]]~~ 1, wherein the Ti layer is formed on the semiconductor layer to function as an ohmic contact layer.
7. (Original): The device according to claim 1, further comprising:
  - a black matrix on a second substrate;
  - a color filter layer on the second substrate; and
  - a liquid crystal material layer between the first and second substrates.

8. (Original): The device according to claim 1, further comprising a TiO<sub>2</sub> layer formed on at least each of the pixel electrodes.
9. (Original): The device according to claim 8, wherein a surface of the TiO<sub>2</sub> layer has hydrophilic properties.
10. (Original): The device according to claim 1, further comprising at least one TiO<sub>2</sub> layer formed in the thin film transistors.
11. (Original): The device according to claim 10, wherein a surface of the TiO<sub>2</sub> layer has hydrophilic properties.
12. (Original): A liquid crystal display device, comprising:
  - a plurality of gate lines and data lines crossing each other to define a plurality of pixel regions;
  - a thin film transistor in each pixel region;
  - a pixel electrode in each pixel region; and
  - a metal masking layer in the thin film transistor.
13. (Original): The device according to claim 12, wherein the metal masking layer includes Ti.

14. (Original): The device according to claim 12, wherein the metal masking layer includes a Ti layer, and a TiO<sub>2</sub> layer having a hydrophilic surface.

Claims 15-70 (Cancelled).

71. (New): The device according to claim 12, wherein the metal masking layer includes Ti and is disposed on upper surfaces of each of a gate electrode, a semiconductor layer and source/drain electrodes of the thin film transistor.